



April 1, 2015

Qiyue Yin
ST UNIV OF NEW YORK at BINGHAMTON
Engineering in Science Building, Mechanical Engineering Department,
Vestal, NY 13850
USA

Dear Qiyue,

I am writing to congratulate you on your successful application for a 2015 M&M Meeting/ Presidential Scholar award, for your paper entitled *"In Situ Visualization of Metallurgical Reactions in Nanoscale Cu/Sn Diffusion Couples"*. Your award is sponsored by the Microscopy Society of America (MSA). The award includes complimentary student registration for the full M&M 2015 meeting and financial support of up to \$1000 to help defray expenses to attend the meeting. ***Additional details on registration and reimbursement procedures will be sent to you in a separate message.***

Your award will be conferred at the Microscopy and Microanalysis 2015 meeting during the opening Plenary Session on the morning of Monday, August 3rd. You will also receive an invitation to the Presidents' Reception, hosted by the Presidents of the Microscopy Society of America (MSA) and the Microanalysis Society (MAS) on Tuesday evening, August 4th. We would also be pleased if you can attend the Student Mixer, Monday afternoon at 5:30 PM, and the MSA Members' Meeting on Wednesday afternoon at 12:15 PM. A drawing will be held during the MSA Members' meeting for a complimentary registration to M&M 2016 in Columbus, OH.

The application pool was extremely competitive this year. Proceedings papers from more than 300 students were reviewed, of which only a small number were selected for M&M Meeting Awards. You and your advisor should be very proud of your excellent work and successful application. Congratulations!

Sincerely,

John F. Mansfield,
President, Microscopy Society of America

CC: Nicole Guy, Robert Dziuban